

Polycrystalline Diamond Slurry

Diamond polycrystalline polishing slurry utilizes the excellent toughness of polycrystalline diamond.

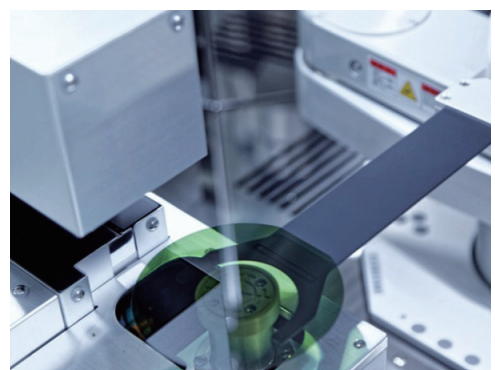
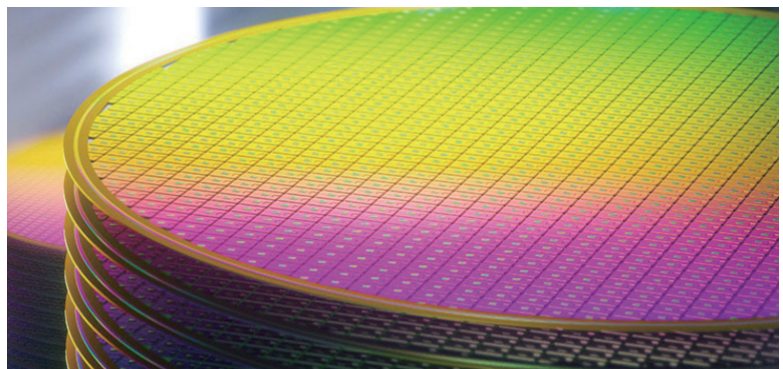
Its special formula ensures good dispersibility and lubrication; it also has good cleaning properties, maintaining high grinding force during polishing while minimizing scratches.

Strict quality control ensures consistent and stable product quality.



The polycrystalline diamond slurry and Pad is mainly developed for the low polishing efficiency of semiconductor and consumer electronics market.

It is applied to thin and polish hard and brittle materials such as sapphire, silicon carbide, silicon wafer and ceramics.



Specifications

Model		Grain
Water based	Oily based	
6μm	6μm	6μm
4μm	4μm	4μm
PC-3μm	3μm	3μm
PC-2μm	2μm	2μm
PC-1μm	1μm	1μm
N500	N500	1/2μm
N250	N250	1/4μm
N200	N200	1/5μm
N100	N100	1/10μm
N50	N50	1/20μm

